L Number	Hits	Search Text	DB	Time stamp
1	2	("5500750").PN.	USPAT;	2004/01/22
			US-PGPUB; EPO; JPO;	17:35
			DERWENT;	
_			IBM_TDB	0004/01/00
5	1186	(349/113).CCLS.	USPAT; US-PGPUB;	2004/01/22
			EPO; JPO;	1,7,13
			DERWENT; IBM TDB	
6	3834	349/\$.ccls. and density	USPAT;	2004/01/22
		•	US-PGPUB;	18:32
			EPO; JPO; DERWENT;	
			IBM_TDB	,
7	80	349/\$.ccls. and density and permeation	USPAT;	2004/01/22 18:44
			US-PGPUB; EPO; JPO;	10:44
			DERWENT;	
	1		IBM_TDB USPAT	2004/01/22
8			JULAI	18:34
9	1		USPAT	2004/01/22
10	1		USPAT	2004/01/22
	_			18:34
11	1		USPAT	2004/01/22   18:35
12	1		USPAT	2004/01/22
13	1	, i	USPAT	18:35 2004/01/22
13	1		OSTAL	18:35
14	1		USPAT	2004/01/22
15	1		USPAT	2004/01/22
1.0	,		USPAT	18:36 2004/01/22
16	1		USPAI	18:36
17	1		USPAT	2004/01/22
18	28	349/\$.ccls. and (density with barrier)	USPAT;	18:36 2004/01/22
		(	US-PGPUB;	18:45
			EPO; JPO; DERWENT;	
			IBM_TDB	
19	22	(349/\$.ccls. and (density with barrier)) not (349/\$.ccls. and density and	USPAT; US-PGPUB;	2004/01/22
		permeation)	EPO; JPO;	10.7/
		; 	DERWENT;	
20	79	349/\$.ccls. and (coating with density)	IBM_TDB USPAT;	2004/01/22
		, , , , , , , , , , , , , , , , , , ,	US-PGPUB;	18:47
1			EPO; JPO; DERWENT;	
			IBM_TDB	
21	73	(349/\$.ccls. and (coating with density)) not (349/\$.ccls. and density and	USPAT; US-PGPUB;	2004/01/22 18:54
		permeation)	EPO; JPO;	
			DERWENT; IBM TDB	
22	34	(((silicon adj (nitride oxide)) with	USPAT;	2004/01/22
		density) ((aluminum adj oxide) with	US-PGPUB;	19:00
		density)) and 349/\$.ccls.	EPO; JPO; DERWENT;	
			IBM_TDB	

23	5916	(((silicon adj (nitride oxide)) with	USPAT;	2004/01/22
23	3510	density) ((aluminum adj oxide) with	US-PGPUB;	19:00
		density))	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
24	350	(((silicon adj (nitride oxide)) with	USPAT;	2004/01/22
		density) ((aluminum adj oxide) with	US-PGPUB;	19:06
		density)) and "liquid crystal"	EPO; JPO;	1
			DERWENT;	
	1		IBM_TDB	
25	316		USPAT;	2004/01/22
		density) ((aluminum adj oxide) with	US-PGPUB;	19:04
		density)) and "liquid crystal" ) not	EPO; JPO;	
		((349/\$.ccls. and density and permeation)	DERWENT;	
		(349/\$.ccls. and (density with barrier))	IBM_TDB	
		(349/\$.ccls. and (coating with density)) ((((silicon adj (nitride oxide)) with		
		(((SIIICON ad) (NICIIde Oxide)) with		<b>j</b>
		density) ((aruminum ad) Oxide) with   density)) and 349/\$.ccls. ))		
27	204	(((silicon adj (nitride oxide)) with	USPAT;	2004/01/22
2 '	201	density) ((aluminum adj oxide) with	US-PGPUB;	19:09
		density)) and (g adj3 (cm cc))	EPO; JPO;	
		=====================================	DERWENT;	
			IBM TDB	
28	119	(((silicon adj (nitride oxide)) with (g	USPAT;	2004/01/22
		adj3 (cm cc))) ((aluminum adj oxide) with	US-PGPUB;	19:39
		(g adj3 (cm cc))))	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
29	61		USPAT;	2004/01/22
		cc))) ((aluminum adj oxide) with (g adj3	US-PGPUB;	19:39
		(cm cc))))	EPO; JPO;	
			DERWENT;	
120	401	(240/1501 - 240/1121 - ) / /	IBM_TDB	2004 (01 (22
30	421	· · · · · · · · · · · · · · · · · · ·	USPAT;	2004/01/22
		sin alo "silicon nitride" "silicon oxide"   "aluminum oxide")	US-PGPUB; EPO; JPO;	19:47
		aruminum oxide /	DERWENT;	
			IBM TDB	
31	0	(polycorbonate with substrate) and	USPAT;	2004/01/22
31		349/\$.ccls.	US-PGPUB;	20:05
			EPO; JPO;	
	1		DERWENT;	
			IBM TDB	
32	400	(polycarbonate with substrate) and	USPAT;	2004/01/22
	1	349/\$.ccls.	US-PGPUB;	20:06
			EPO; JPO;	
			DERWENT;	
	1		IBM TDB	